What is Claimed:

10.

carrier with a continuous outer well.

1 2

The process of claim 9 further comprising providing the chip

1	11. The process of claim 8 further comprising shipping the chip carries		
2	from a first location to a second location.		
1	12. A method for manufacturing an electronic component comprising:		
2	receiving a chip carrier including a base, an inner well formed about the		
3	periphery of the base, an outer well formed about the periphery of the inner well, and an		
4	integrated circuit positioned on the base; and		
5	retrieving the integrated circuit from chip carrier.		
1	13. The method according to claim 12 further comprising positioning		
2	the retrieved integrated circuit on a circuit board.		
1	14. A carrier comprising:		
2	an upper surface defining a first reference plane;		
3	a first wall extending away from the reference plane towards a first		
4	position;		
5	a second wall extending away from the first position towards the reference		
6	plane;		
7	a third wall extending away from the reference plane towards a second		
8	position; and		
9	a base positioned below the first reference plane		
1	15. The carrier according to claim 14 wherein the first position is		
2	further from the reference plane than the second position.		
1	16. The carrier according to claim 14 wherein:		
2	the base defines a second reference plane positioned below the first		
3	reference plane;		
4	the third position is located below the second reference plane; and		
5	the first position is located below the second reference plane.		
1	17. The carrier according to claim 14 wherein the first wall and the		
2	second wall form a first well.		

1	18.	The carrier according to claim 17 wherein the third wall and the	
2	fourth wall form a second well.		
1	19.	The carrier according to claim 14 wherein the third wall and the	
2	fourth wall form a well.		
1	20.	A method of transporting a device comprising:	
2	providi	ng a carrier including a base, an inner well formed about the	
3	periphery of the base, and an outer well formed about the periphery of the inner well; and		
4	moving	the device from a first location to a second location in the carrier	